L Number	Hits	Search Text	DB	Time stamp
54	1	((yoon near3 tae-ho) (roh near3 joon)).in. and (discharge plasma)	USPAT;	2004/03/10 13:37
			US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
			IBM_TDB	
55	15	(kwangju).as. and plasma	USPAT;	2004/03/10 12:49
			US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
			IBM_TDB	
56	1910	(kwangju).as.	USPAT;	2004/03/10 12:49
			US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
			IBM_TDB	
57	182	((kwangju).as. ) and (discharge corona plasma)	USPAT;	2004/03/10 12:55
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
58	1	((yoon near3 tae-ho) (roh near3 joon)).in. and (discharge corona plasma)	USPAT;	2004/03/10 12:50
			US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
			IBM TDB	
59	6	((yoon near3 tae-ho) (roh near3 joon)).in.	USPĀT;	2004/03/10 12:50
	_	(()	US-PGPUB,	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
60	1	(((kwangju).as.) and (discharge corona plasma)) and	USPAT;	2004/03/10 12:54
		(diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene	US-PGPUB;	•
		allylmercaptan allyl\$1thiol thiol)	EPO; JPO;	
		· ·	DERWENT;	
			IBM_TDB	
61	808	(discharge corona plasma) same (diamino\$1propane pyrrole	USPAT;	2004/03/10 17:52
	000	epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol thiol)	US-PGPUB;	2001105,101,132
		epoxywonekene gryerawonekene arrynnereapaar arrynwranior anory	EPO; JPO;	
			DERWENT;	
			IBM TDB	
62	19	((discharge corona plasma) same (diamino\$1propane pyrrole	USPAT;	2004/03/10 17:51
02	17	epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol thiol)) same	US-PGPUB;	200 1103/10 17:51
		(silica (silicon near5 (dioxide oxide)))	EPO; JPO;	
		(Sinea (Sinear) (Gloride Oride)))	DERWENT;	
			IBM_TDB	
64	116	(discharge corona plasma) near9 (polymeri\$8 coat\$3 deposit\$8	USPAT;	2004/03/10 14:30
	110	modif\$7) same (diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB;	200 1/03/10 11:30
		glycid\$5hexene allylmercaptan allyl\$1thiol thiol)	EPO; JPO;	
		grycid#3nexenc arryintereaptain arryi#1tinor tinory	DERWENT;	
			IBM_TDB	
65	25	((discharge corona plasma) near9 (polymeri\$8 coat\$3 deposit\$8	USPAT;	2004/03/10 14:27
(0)	23		US-PGPUB;	2007/03/10 14.2/
		modif\$7) same (diamino\$1 propane pyrrole epoxy\$3 hexene		
		glycid\$5hexene allylmercaptan allyl\$1thiol thiol)) same (particle	EPO; JPO;	
		particulate filler oxide silica (silicon near5 (dioxide oxide)))	DERWENT;	
	22	(1:-1	IBM_TDB	2004/02/10 14:40
66	22	(discharge corona plasma) near9 (polymeri\$8 coat\$3 deposit\$8) near9	USPAT;	2004/03/10 14:40
		(diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene	US-PGPUB;	
		allylmercaptan allyl\$1thiol thiol)	ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	

medit\$9) near9 surface and (diamino\$1 propane pyrrole epoxy\$3 hexene glyxid\$5 hexene allylmcreaptan allyl\$1 thiol thiol)   DERWENT;   BM TDB   USFAT;   BM	(7	1 000	(discharge corona plasma) near9 (polymeri\$8 coat\$3 deposit\$8	USPAT;	2004/03/10 14:42
225   (discharge corona plasma) near9 modif89 near9 surface and (diamino51 proprane pyrrole epoxy\$3hexene glycid\$5hexene gly	67	800			2004/03/10 14:42
				1	
225   (discharge corona plasma) near9 modif\$9 near9 surface and (dismino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol thiol)   USPAT; USPGPUB; BIFO; JPO; DERWENT; BIM, TDB; USPAGPUB; BIFO; JPO; DERWENT; BIM, TDB			glycidsonexene anyimercapian anyis i unoi)	1	
225   Glischarge corona plasma) nearly modifS9 nearly surface and Glinding Iropane provide cpoxy33hexene glycid\$5hexene   USPAT; USPAT; IBM_TDB   2004/03/10 14-47   2004/03/10 14-57   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07   2004/03/10 15-07				1	
	60	225	(1) 1	· —	2004/02/10 14:44
allylmercopton allyl\$1 thiot thiot)   IPO, IPO, IPO, DERWENT, BM TDB   USPAT, US-PGPUB, epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiot thiot)   IPO, IPO, IPO, IPO, IPO, IPO, IPO, IPO,	68	225		1	2004/03/10 14:44
1				· ·	
11   discharge corona plasma) near9 modis9 near9 surface same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allyfareraptan allyf\$1 thiol thiol)   14.47   15.47			allylmercaptan allylylthiol thiol)		
1					
	6.0				2004/02/10 14 47
allylmercaptan allyl\$1thiol (thiol)  228 (discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1thiol thiol)  5 ((discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol thiol)  72 41 (discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol)  73 41 (discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol)  74 10 ((discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 (modif\$9 coat\$3 polymerf\$9 depoxi\$9) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 functional\$9) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 functional\$9) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 functional\$9) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glyeid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  78	69	11	1 '	1	2004/03/10 14:47
DERWENT: IBM_TDB   USPAT; US-RGPUB; PFO, IPO, DIRWENT: IBM_TDB   USPAT; US-RGPUB; PFO, IPO, DIRWENT: IBM_TDB   USPAT; US-RGPUB; PFO, IPO, DIRWENT; IBM_TDB   USPAT; US-RGPUB; PFO, IPO, IPO, DIRWENT; IBM_TDB   USPAT; US-RGPUB; PFO, IPO, IPO, DIRWENT; IBM_TDB   USPAT; US-RGPUB; PFO, IPO, IPO, DIRWENT; IBM_TDB   USPAT; US-RGPUB; IPO, IPO, IPO, DIRWENT; IBM_TDB   USPAT; US-RGPUB; IPO, IPO, IPO, IPO, DIRWENT; IBM_TDB   USPAT; US-RGPUB; IPO, IPO, IPO, IPO, IPO, IPO, IPO, IPO,					
228   (discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol thiol)   USPGFUB, EPO, FPO, DERWENT, BM, TDB   USPAT; USPGFUB, EPO, FPO, DERWENT, BM, TDB   USPAT;			allylmercaptan allylylthiol thiol)	1	
228   (discharge corona plasma) near9 (diamino\$1 propane pyrrole coxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol thiol)   USPAT; US-PGPUB; EPO; BPO; DERWENT; BM TDB USPAT; US-PGPUB; EPO; BPO; BPO; BPO; BPO; BPO; BPO; BPO; B					
epoxy\$3hexene glycid\$Shexene allylmercaptan allyl\$1thiol thiol)   USP-GFUB	<b>7</b> 0	220		_	2004/02/10 14.52
71 5 ((discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol thiol) ) and modi\$9 near3 surface near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  72 41 (discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol)	70	228			2004/03/10 14:52
The composition of the composi			epoxy\$3nexene glycid\$5nexene allylmercaptan allyl\$1thiol thiol)	· ·	
Second   Comparison   Compari				1 '	
10				1	
epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol thiol) and modif\$9 near3 surface near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))   EPO, IPO, DERWENT; BM, TDB   USPAT; US-PGPUB; EPO, IPO, DERWENT; BM, TDB   US	<b>.</b>	_		-	2004/02/10 14:52
modif\$9 near3 surface near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  24	71	5		1	2004/03/10 14:53
(silicon near5 (dioxide oxide))				1	
To			\		
10   (discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)   USPAT; US-PGPUB; EPO, IPO, DERWENT; IBM_TDB   USPAT; US-PGPUB; EPO, IPO, DERWENT; IBM_TDB   USPAT; US-PGPUB; EPO, IPO, DERWENT; IBM_TDB   USPAT; USPAT			(silicon nears (dioxide oxide)))	1	
cpoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  US-PGPUB, EPO, IPO, DERWENT; IBM_TDB USPAT; US-PGPUB, cpoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 coat\$3 polymeri\$9 deposit\$9) near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  75  2 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  8 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77  199  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  78  5	70	41	(1'-1	_	2004/02/10 14:50
74 10 (((discharge corona plasma) near9 ((diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and ((modif\$9 coat\$3 polymeri\$9 deposit\$9) near9 (particle particulate filler oxide silica (silicon near5 ((dioxide oxide)))  75 2 (((discharge corona plasma) near9 ((diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol)) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 ((dioxide oxide)))  76 4 (((discharge corona plasma) near9 ((diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol)) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77 199 (discharge corona plasma) same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) us. PGPUB; EPO; JPO; DERWENT; IBM_TDB  78 55 (((discharge corona plasma) same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 (((discharge corona plasma) same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol)) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  8 2004/03/10 15:27  2004/03/10 15:27  2004/03/10 15:27  2004/03/10 15:27  2004/03/10 15:27  2004/03/10 15:31	/2	41		1	2004/03/10 14:39
74 10 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 coat\$3 polymeri\$9 deposit\$9) near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  75 2 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  76 4 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77 199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) us-PGPUB; EPO; PO; DERWENT; BM_TDB  78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  8 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  8 18 ((discharge corona plasma) same (diamino\$1pro			epoxy\$3nexene glycid\$5nexene allylmercapian allyl\$1tmol)	1	
74   10 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 coat\$3 polymeri\$9 deposit\$9) near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  75   2 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  76   4 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77   199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  78   55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79   18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))					
10				_	
cpoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 coatf\$3 polymeri\$9 deposit\$9) near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))   DERWENT;   BM_TDB   USPAT;   USPA	74	10	((discharge earone plagme) near() (diamine \$1 propens purrale	_	2004/03/10 14:56
(modit\$9 coat\$3 polymeri\$9 deposit\$9) near9 (particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  2 ((discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  4 ((discharge corona plasma) near9 (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77 199 (discharge corona plasma) same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol)  78 55 ((discharge corona plasma) same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  8 55 ((discharge corona plasma) same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1 propane pyrrole epoxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 (substrate surface ceramic glass particle poxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle poxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle poxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle poxy\$3 hexene glycid\$5 hexene allylmercaptan allyl\$1 thiol) and (modit\$9 functional\$9) near9 surface near9 (sub	/4	10			2004/03/10 14.50
oxide silica (silicon near5 (dioxide oxide)))  DERWENT; BM_TDB (discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (modif\$9 functional\$9) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (modif\$9 functional\$9) near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))					
2 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  76				, ,	
2 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  4 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77 199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass			oxide sinca (sincon near) (dioxide oxide)))		
epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  76  4 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77  199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  78  55 (((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79  18 (((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 (((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  2004/03/10 15:00  2004/03/10 15:00  2004/03/10 15:00  2004/03/10 15:00  2004/03/10 15:00  2004/03/10 15:00	75	2	((discharge corone plasme) near() (diamino\$1 propens purrole	-	2004/03/10 14:57
(modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))	/3	2		,	2004/03/10 14.37
particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)  (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)				1	
199   (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))   DERWENT; IBM_TDB (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)   US-PGPUB; EPO; JPO; DERWENT; IBM_TDB (US-PGPUB; EPO; JPO; DERWENT; IBM_TDB (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)   uspart; USPAT; USPAT			`		
4 ((discharge corona plasma) near9 (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  77 199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))			particle particulate filler oxide silica (silicon flear) (dioxide oxide)))	-	
epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  109 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)  18 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)  18 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)	76	4	((discharge corone plasma) near (diamino \$1 propaga pyrrala	_	2004/03/10 15:00
(modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  199 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  180 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  180 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  180 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (US-PGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (US-PGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (US-PGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (USPGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (USPGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (USPGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (USPGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (USPGPUB; EPO; JPO; DERWENT; IBM_TDB (USPAT; epoxy\$3hexene glycid\$5hexene epoxy\$3hexene glycid\$5hexene epoxy\$3hexene epoxy\$3hexene epoxy\$3hexene e	/0	-	1 '		2004/03/10 19:00
particulate filler oxide silica (silicon near5 (dioxide oxide)))  199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  78					
77 199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  EPO; JPO; DERWENT; IBM_TDB (USPAT; USPAT; USPAT; EPO; JPO; DERWENT) (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass) (EPO; JPO;				1 1	
77 199 (discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  18 (EPO; JPO; JPO; JPO; JPO; JPO; JPO; JPO; J			particulate finer oxide sinea (sincon hears (dioxide oxide)))	_	
epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)  US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO; EPO; JPO; DERWENT; IBM_TDB USPAT; USPAT; USPAT; Epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;	77	199	(discharge corona, plasma) same (diamino\$1 propage pyrrole	****	2004/03/10 15:27
78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;	' '	1,75			200 1, 00, 10 10 10
78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;			epony with the griffic desired any more apain any tunor,	1	
78 55 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  79 18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) ) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;				1	
((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass)				1	
epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  US-PGPUB; EPO; JPO; USPAT; US-PGPUB; EPO; JPO; EPO; JPO;	78	55	((discharge corona, plasma) same (diamino\$1 propane pyrrole	_	2004/03/10 15:00
(modif\$9 functional\$9) near9 (substrate surface ceramic glass particle particulate filler oxide silica (silicon near5 (dioxide oxide)))  18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  EPO; JPO; DERWENT; IBM_TDB USPAT; USPAT; USPAT; US-PGPUB; EPO; JPO;				1	
particulate filler oxide silica (silicon near5 (dioxide oxide)))  DERWENT; IBM_TDB  ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass  DERWENT; IBM_TDB  USPAT; US-PGPUB; EPO; JPO;				1	
18 ((discharge corona plasma) same (diamino\$1propane pyrrole uSPAT; 2004/03/10 15:31 epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;			1 '	1 1	
18 ((discharge corona plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)) and (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;			parational control (masses control (masses control))		
epoxy\$3hexene glycid\$5hexene allylmercaptan allyl\$1thiol)) and US-PGPUB; (modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;	79	18	((discharge corona plasma) same (diamino\$1propane pyrrole	_	2004/03/10 15:31
(modif\$9 functional\$9) near9 surface near9 (substrate ceramic glass EPO; JPO;				1	
				1	
particle particulate filler oxide silica (silicon near5 (dioxide oxide)))   DERWENT;			particle particulate filler oxide silica (silicon near5 (dioxide oxide)))	DERWENT;	
IBM_TDB					

	<del>-,</del>			
80	199	(discharge corona plasma) same (diamino\$1propane pyrrole	USPAT;	2004/03/10 15:30
		epoxy\$3hexene glycid\$5hexene allylmercaptan propene\$1thiol)	US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
0.1			IBM_TDB	
81	67	(discharge corona plasma) same polymeri\$8 same (diamino\$1propane	USPAT;	2004/03/10 15:40
		pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan propene\$1thiol)	US-PGPUB;	
			ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	
82	34	((discharge corona plasma) same polymeri\$8 same (diamino\$1propane	USPAT;	2004/03/10 15:41
		pyrrole epoxy\$3hexene glycid\$5hexene allylmercaptan propene\$1thiol)	US-PGPUB;	
		) and (particle particulate filler oxide silica (silicon near5 (dioxide	ЕРО; ЛРО;	
		oxide)))	DERWENT;	
			IBM_TDB	
83	94	(discharge corona plasma) same (polymeri\$8 deposit\$9 treat\$9	USPAT;	2004/03/10 15:47
		modif\$9) same (diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB;	
		glycid\$5hexene allylmercaptan propene\$1thiol)	ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	
84	43	((discharge corona plasma) same (polymeri\$8 deposit\$9 treat\$9	USPĀT;	2004/03/10 15:41
		modif\$9) same (diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB;	
		glycid\$5hexene allylmercaptan propene\$1thiol)) and (particle	ЕРО; ЛРО;	
		particulate filler (metal near oxide) silica (silicon near5 (dioxide	DERWENT;	
		oxide)))	IBM TDB	
85	10	((discharge corona plasma) same (polymeri\$8 deposit\$9 treat\$9	USPĀT;	2004/03/10 16:27
	*	modif\$9) same (diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB;	
		glycid\$5hexene allylmercaptan propene\$1thiol)) same (particle	EPO, JPO,	
		particulate filler (metal near oxide) silica (silicon near5 (dioxide	DERWENT;	
		oxide)))	IBM_TDB	
86	33	(((discharge corona plasma) same (polymeri\$8 deposit\$9 treat\$9	USPĀT;	2004/03/10 15:43
		modif\$9) same (diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB;	
		glycid\$5hexene allylmercaptan propene\$1thiol)) and (particle	ЕРО; ЈРО;	
		particulate filler (metal near oxide) silica (silicon near5 (dioxide	DERWENT;	
		oxide)))) not (((discharge corona plasma) same (polymeri\$8 deposit\$9	IBM TDB	
		treat\$9 modif\$9) same (diamino\$1 propane pyrrole epoxy\$3hexene	_	
		glycid\$5hexene allylmercaptan propene\$1thiol)) same (particle		
		particulate filler (metal near oxide) silica (silicon near5 (dioxide		
		oxide)))))		
88	5	(((discharge near3 (glow corona)) plasma) same (polymeri\$8 deposit\$9	USPAT;	2004/03/10 16:00
	]	treat\$9 modif\$9) same (diamino\$1 propane pyrrole epoxy\$3 hexene	US-PGPUB;	10.00
		glycid\$5hexene allylmercaptan propene\$1thiol)) same (particle	ЕРО; ЛРО;	
		particulate filler (metal near oxide) silica (silicon near5 (dioxide	DERWENT;	
		oxide)))	IBM TDB	
87	59	((discharge near3 (glow corona)) plasma) same (polymeri\$8 deposit\$9	USPAT;	2004/03/10 16:00
		treat\$9 modif\$9) same (diamino\$1 propane pyrrole epoxy\$3 hexene	US-PGPUB;	10.00
		glycid\$5hexene allylmercaptan propene\$1thiol)	EPO; JPO;	
		, , , , , , , , , , , , , , , , , , , ,	DERWENT;	
			IBM TDB	
89	28	((discharge near3 (glow corona)) plasma) same (polymeri\$8 deposit\$9	USPAT;	2004/03/10 16:02
		treat\$9 modif\$9) same (epoxy\$3hexene glycid\$5hexene \$9mercaptan	US-PGPUB;	200 1100/10 10:02
		propene\$1thiol)	EPO; JPO;	
		. L L	DERWENT;	
			IBM_TDB	
90	2	((discharge near3 (glow corona)) plasma) same (polymeri\$8 deposit\$9	USPAT;	2004/03/10 16:05
<i>y</i> <b>G</b>		treat\$9 modif\$9) same (epoxy\$3hexene glycid\$5hexene	US-PGPUB;	2004/03/10 10:03
		allyl\$3mercaptan propen\$4 near3 (thiol mercaptan) propene\$1thiol)	ЕРО; ЛРО;	-
		angrasmoreapum propentas nears (unoi mercapum) propenes i unoi)	DERWENT:	
			IBM_TDB	
	<u> </u>		תסומד דמונתו	

91	2	((discharge near3 (glow corona)) plasma) same (polymeri\$8 deposit\$9	USPAT;	2004/03/10 16:05
		treat\$9 modif\$9) same (epoxy\$3hexene glycid\$5hexene	US-PGPUB;	
		allyl\$3mercaptan ((propylene alkylene) near3 (thiol mercaptan))	ЕРО; ЛРО;	
		propene\$1thiol)	DERWENT;	
			IBM_TDB	
92	2	((discharge near3 (glow corona)) plasma) same polymeri\$8 same	USPAT;	2004/03/10 16:05
, <del>-</del>		(epoxy\$3hexene glycid\$5hexene allyl\$3mercaptan ((propylene alkylene)	US-PGPUB;	
		near3 (thiol mercaptan)) propene\$1thiol)	ЕРО; ЛРО;	
			DERWENT;	
			IBM TDB	
0.3	24	(/1: 1 2 / /1-w ) wlooms) same nalymerith some	USPAT;	2004/03/10 17:15
93	34	((discharge near3 (glow corona)) plasma) same polymeri\$8 same	1	2004/03/10 17.13
		(iamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene	US-PGPUB;	
		allyl\$3mercaptan ((propylene alkylene) near3 (thiol mercaptan))	ЕРО; ЛРО;	
		propene\$1thio1)	DERWENT;	
			IBM_TDB	
94	38	((discharge near3 (glow corona)) plasma) same polymeri\$8 same	USPAT;	2004/03/10 16:26
		(diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene	US-PGPUB;	
		allyl\$3mercaptan ((propylene alkylene) near3 (thiol mercaptan))	ЕРО; ЈРО;	
		propene\$1thiol)	DERWENT;	
			IBM TDB	
95	82	((discharge near3 (glow corona)) plasma) same (diamino\$1propane	USPAT;	2004/03/10 16:53
,,,		pyrrole epoxy\$3hexene glycid\$5hexene allyl\$3mercaptan ((propylene	US-PGPUB;	
		alkylene) near3 (thiol mercaptan)) propene\$1thiol)	ЕРО; ЈРО;	
		arkytency hears (untor increaptanty) propercure and the	DERWENT;	
			IBM TDB	
0.6		(/1: 1		2004/03/10 16:48
96	31	((discharge corona plasma) same (polymeri\$8 deposit\$9 treat\$9	USPAT;	2004/03/10 10.46
		modif\$9) same (diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB;	
		glycid\$5hexene allylmercaptan propene\$1thiol) ) and (((ceramic glass	ЕРО; ЛРО;	
		mineral inorganic (metal near oxide)) near3 (filler particle particulate	DERWENT;	
		powder\$3)) silica ((silicon alumium al Si) near5 (dioxide oxide))	IBM_TDB	
		alumina clay talc mica)		
97	17	adhesi\$6 near9 interface near9 (resin matrix) and (funtional\$9 modif\$8)	USPAT;	2004/03/10 16:52
		near9 surface near9 (silica ((silicon alumium al Si) near5 (dioxide	US-PGPUB;	
		oxide)) pigment filler alumina clay talc mica)	ЕРО; ЛРО;	
			DERWENT,	
			IBM TDB	<u> </u>
98	208	adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) near9 (resin	USPAT;	2004/03/10 18:00
, ,		matrix) and (funtional\$9 modif\$8) near9 surface near9 (silica ((silicon	US-PGPUB;	-
		alumium al Si) near5 (dioxide oxide)) pigment filler alumina clay talc	ЕРО; ЛРО;	
		mica)	DERWENT;	
		inicaj	IBM TDB	
00	16	((discharge near3 (glow corona)) plasma) and (adhesi\$6 near9	USPAT;	2004/03/10 17:01
99	46	, , , , , , , , , , , , , , , , , , ,	US-PGPUB;	200 1103/10 17.01
		(improve\$6 interface enhanc\$6 increas\$8) near9 (resin matrix) and		*
		(funtional\$9 modif\$8) near9 surface near9 (silica ((silicon alumium al	EPO; JPO;	
		Si) near5 (dioxide oxide)) pigment filler alumina clay talc mica))	DERWENT;	
			IBM_TDB	2004/02/10 17 11
100	6911	adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) and	USPAT;	2004/03/10 17:11
		(funtional\$9 modif\$8 coat\$3) near9 (silica ((silicon alumium al Si)	US-PGPUB;	
		near5 (dioxide oxide)))	ЕРО; ЛРО;	
		·	DERWENT;	
			IBM_TDB	
101	. 2723	((discharge near3 (glow corona)) plasma) and (adhesi\$6 near9	USPAT;	2004/03/10 17:11
		(improve\$6 interface enhanc\$6 increas\$8) and (funtional\$9 modif\$8	US-PGPUB;	
		coat\$3) near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))))	ЕРО; ЛРО;	
		× (	DERWENT;	
		·	IBM_TDB	
102	378	adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) and	USPAT;	2004/03/10 17:03
102	376		US-PGPUB;	
		(funtional\$9 modif\$8 coat\$3) near9 (silica ((silicon alumium al Si)		
		near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)	EPO; JPO;	
			DERWENT;	
			IBM_TDB	

103	44	adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) same	USPAT;	2004/03/10 17:04
į		(funtional\$9 modif\$8 coat\$3) near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)	US-PGPUB; EPO; JPO; DERWENT;	
104	42	adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) and (funtional\$9 modif\$8) near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/03/10 17:14
105	33	(adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) and (funtional\$9 modif\$8) near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)) not (adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) same (funtional\$9 modif\$8 coat\$3) near9 (silica ((silicon alumium al Si)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 17:12
106	63	near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)) (funtional\$9 modif\$8) near9 surface near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/03/10 17:16
107	35	(funtional\$9 modif\$8) near9 surface near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) near9 ((discharge near3 (glow corona)) plasma)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/03/10 17:14
109	2	(funtional\$9 modif\$8 polymeri\$9) near9 surface near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma) same (diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene allyl\$3mercaptan ((propylene alkylene) near3 (thiol	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/03/10 17:18
110	3	mercaptan)) propene\$1thiol) (funtional\$9 modif\$8 polymeri\$9) near9 surface near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma) same (allylamine acrylic glycidyl acrylate acrylamide ethyleneimine acrylonitrile pyridine diamino\$1 propane pyrrole epoxy\$3hexene glycid\$5hexene allyl\$3mercaptan ((propylene alkylene)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 17:20
111	7	near3 (thiol mercaptan)) propene\$1thiol) (funtional\$9 modif\$8 polymeri\$9) near9 surface near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) and ((discharge near3 (glow corona)) plasma) near9 (allylamine acrylic glycidyl acrylate acrylamide ethyleneimine acrylonitrile pyridine diamino\$1 propane pyrrole	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/10 17:22
112	36	epoxy\$3hexene glycid\$5hexene allyl\$3mercaptan ((propylene alkylene) near3 (thiol mercaptan)) propene\$1thiol) (funtional\$9 modif\$8 polymeri\$9) near9 surface near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) and ((discharge near3 (glow corona)) plasma) same (allylamine acrylic glycidyl acrylate acrylamide ethyleneimine acrylonitrile pyridine diamino\$1 propane pyrrole epoxy\$3hexene glycid\$5hexene allyl\$3mercaptan ((propylene alkylene)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 17:44
113	11	near3 (thiol mercaptan)) propene\$1thiol) (funtional\$9 modif\$8 polymeri\$9 treat\$9) near9 (silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma) same (allylamine glycidyl allyl acrylamide ethyleneimine acrylonitrile pyridine diamino\$1 propane pyrrole epoxy\$3hexene glycid\$5hexene allyl\$3mercaptan ((propylene alkylene)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 17:30
114	0	near3 (thiol mercaptan)) propene\$1thiol) intoduc\$6 near9 (functional\$9 ((amino thiol) near3 group)) near9 surface near9 (filler silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/10 17:34

115	1.4	(C (' 100 (( ' 11-1) 2 )) 0 C 0 (Ellon	HCD AT-	2004/02/10 17:27
115	14	(functional\$9 ((amino thiol) near3 group)) near9 surface near9 (filler	USPAT;	2004/03/10 17:37
		silica ((silicon alumium al Si) near5 (dioxide oxide))) same ((discharge	US-PGPUB;	
		near3 (glow corona)) plasma)	ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	2004/02/10 15 20
116	15	(functional\$9 amino thiol) near9 surface near9 (filler silica ((silicon	USPAT;	2004/03/10 17:39
		alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow	US-PGPUB;	
		corona)) plasma)	ЕРО; ЈРО;	
			DERWENT;	
			IBM_TDB	
118	1	( (functional\$9 amino thiol) near9 surface near9 (filler silica ((silicon	USPAT;	2004/03/10 17:38
	!	alumium al Si) near5 (dioxide oxide))) same ((discharge near3 (glow	US-PGPUB;	
	,	corona)) plasma)) not ( (functional\$9 ((amino thiol) near3 group)) near9	ЕРО; ЈРО;	
	!	surface near9 (filler silica ((silicon alumium al Si) near5 (dioxide	DERWENT;	
	1	oxide))) same ((discharge near3 (glow corona)) plasma))	IBM TDB	
119	88	(functional\$9 amino thiol) near9 (filler silica ((silicon alumium al Si)	USPAT;	2004/03/10 17:40
119	00		US-PGPUB;	2004/03/10 17.40
		near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)	1	
			ЕРО; ЈРО;	
	1		DERWENT;	
			IBM_TDB	
120	19	(functional\$9 amino thiol) near9 (filler silica ((silicon alumium al Si)	USPAT;	2004/03/10 17:41
		near5 (dioxide oxide))) same ((discharge near3 (glow corona)) plasma)	US-PGPUB;	
		near9 (polymeri\$9 treat\$9 modif\$8)	ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	
121	3688	(filler silica ((silicon alumium al Si) near5 (dioxide oxide))) same	USPAT;	2004/03/10 17:42
		((discharge near3 (glow corona)) plasma) near9 (polymeri\$9 treat\$9	US-PGPUB;	
		modif\$8 functional\$9 amino thiol)	ЕРО, ЈРО,	
		modify tune and a more	DERWENT;	
			IBM TDB	
100	1200	(filler silica ((silicon alumium al Si) near5 (dioxide oxide))) near9	USPAT;	2004/03/10 17:42
122	1388		US-PGPUB;	2004/03/10 17.42
		((discharge near3 (glow corona)) plasma) near9 (polymeri\$9 treat\$9	1	
		modif\$8 functional\$9 amino thiol)	ЕРО; ЛРО;	*
			DERWENT;	
			IBM_TDB	2004/02/10 17 42
123	946	(filler silica ((silicon alumium al Si) near5 (dioxide oxide))) near9	USPAT;	2004/03/10 17:43
		surface same ((discharge near3 (glow corona)) plasma) near9	US-PGPUB;	
		(polymeri\$9 treat\$9 modif\$8 functional\$9 amino thiol)	ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	
124	470	(filler silica ((silicon alumium al Si) near5 (dioxide oxide))) near9	USPAT;	2004/03/10 17:43
		surface near9 ((discharge near3 (glow corona)) plasma) near9	US-PGPUB;	
		(polymeri\$9 treat\$9 modif\$8 functional\$9 amino thiol)	ЕРО; ЈРО;	
		(pasyament) at the same and a same as a same a	DERWENT;	
			IBM TDB	
125	76	( (filler silica ((silicon alumium al Si) near5 (dioxide oxide))) near9	USPAT;	2004/03/10 17:46
	/0	surface same ((discharge near3 (glow corona)) plasma) near9	US-PGPUB;	
		(polymeri\$9 treat\$9 modif\$8 functional\$9 amino thiol)) same	EPO; JPO;	
	-		DERWENT;	
		(allylamine acrylic glycidyl acrylate acrylamide ethyleneimine	1	
		acrylonitrile pyridine diamino\$1propane pyrrole epoxy\$3hexene	IBM_TDB	
		glycid\$5hexene allyl\$3mercaptan ((propylene alkylene) near3 (thiol		
		mercaptan)) propene\$1thiol)	LIGH. T	2004/02/10 10 50
126	12	( (filler silica ((silicon alumium al Si) near5 (dioxide oxide))) near9	USPAT;	2004/03/10 18:59
		surface same ((discharge near3 (glow corona)) plasma) near9	US-PGPUB;	1
		(polymeri\$9 treat\$9 modif\$8 functional\$9 amino thiol)) same	ЕРО; ЛРО;	1
		(allylamine allyl glycidyl acrylamide ethyleneimine acrylonitrile	DERWENT;	
		pyridine diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene	IBM_TDB	
		allyl\$3mercaptan ((propylene alkylene) near3 (thiol mercaptan))	_	
		propene\$1thiol)		
	1	FF		

127	1	"4606930" and silica	USPAT; US-PGPUB;	2004/03/10 17:51
			EPO; JPO;	
			DERWENT,	
100	1.450		IBM_TDB	2004/02/10 17 51
128	1470	surface near3 modif\$6 near3 (silica (silicon near5 (dioxide oxide)))	USPAT; US-PGPUB;	2004/03/10 17:51
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
129	3	(surface near3 modif\$6 near3 (silica (silicon near5 (dioxide oxide))))	USPAT;	2004/03/10 17:53
		same (discharge corona plasma) near9 (polymeri\$9 monomer)	US-PGPUB; EPO; JPO;	
		*	DERWENT;	
			IBM_TDB	
130	17	(surface near3 modif\$6 near3 (silica (silicon near5 (dioxide oxide))))	USPAT;	2004/03/10 17:59
		and (discharge corona plasma) near9 (polymeri\$9 monomer)	US-PGPUB; EPO; JPO;	
			DERWENT;	
			IBM_TDB	
131	218	(surface near3 modif\$6 near3 (silica (silicon near5 (dioxide oxide))))	USPAT;	2004/03/10 17:55
		and (discharge corona plasma)	US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM TDB	
132	15	(surface near3 modif\$6 near3 (silica (silicon near5 (dioxide oxide))))	USPĀT;	2004/03/10 17:56
		same (discharge corona plasma)	US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM TDB	
133	2897	(silica (silicon near5 (dioxide oxide))) same (discharge corona plasma)	USPAT;	2004/03/10 18:05
		near9 (treat\$5 functionali\$9 modif\$8)	US-PGPUB;	
			EPO; JPO;	
			DERWENT; IBM_TDB	
134	81	adhesi\$6 near9 (improve\$6 interface enhanc\$6 increas\$8) near9 (resin	USPAT;	2004/03/10 18:06
		matrix) and ((silica (silicon near5 (dioxide oxide))) same (discharge	US-PGPUB;	
		corona plasma) near9 (treat\$5 functionali\$9 modif\$8))	ЕРО; ЈРО;	
			DERWENT; IBM_TDB	
135	1151	(silica (silicon near5 (dioxide oxide))) near9 (treat\$5 functionali\$9	USPAT;	2004/03/10 18:05
		modif\$8) near9 (discharge corona plasma)	US-PGPUB;	
-			EPO; JPO;	
			DERWENT; IBM TDB	
136	191	(silica (silicon near5 (dioxide oxide))) near3 surface near9 (treat\$5	USPAT;	2004/03/10 19:01
		functionali\$9 modif\$8) near9 (discharge corona plasma)	US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
138	25	(adhesi\$6 dispers\$9) near9 (resin matrix interface) and ((silica (silicon	IBM_TDB USPAT;	2004/03/10 18:07
100		near5 (dioxide oxide))) near3 surface near9 (treat\$5 functionali\$9	US-PGPUB;	200 1100110 10.07
		modif\$8) near9 (discharge corona plasma) )	ЕРО; ЈРО;	
			DERWENT;	
137	58	adhesi\$6 near9 (promot\$9 improve\$6 interface enhanc\$6 increas\$8) and	IBM_TDB USPAT;	2004/03/10 18:10
1 3 1	] 30	((silica (silicon near5 (dioxide oxide))) near3 surface near9 (treat\$5	US-PGPUB;	2004/03/10 10.10
		functionali\$9 modif\$8) near9 (discharge corona plasma))	ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	<u> </u>

			I I CDATE	0004/02/10 10 10
139	1	filler near9 (silica (silicon near5 (dioxide oxide))) near3 surface near9	USPAT;	2004/03/10 18:12
		(treat\$5 functionali\$9 modif\$8) near9 (discharge corona plasma)	US-PGPUB;	
			ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	
140	8	filler near9 (silica (silicon near5 (dioxide oxide))) near9 (treat\$5	USPAT;	2004/03/10 18:12
		functionali\$9 modif\$8) near9 (discharge corona plasma)	US-PGPUB;	
			ЕРО; ЛРО;	
			DERWENT;	
	-		IBM_TDB	
141	60	filler near9 (treat\$5 functionali\$9 modif\$8) near9 (discharge corona	USPAT;	2004/03/10 18:51
141	00	plasma) and (silica (silicon near5 (dioxide oxide)))	US-PGPUB;	2004/03/10 10.31
		plasma) and (sinea (sineon hears (dioxide oxide)))	EPO; JPO;	
			1 -	
			DERWENT;	
			IBM_TDB	0004/00/10 10 51
142	1	Interfacial near3 Strength near9 Composite same plasma near9 filler	USPAT;	2004/03/10 18:51
			US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
			IBM_TDB	
143	2	Interfac\$4 near9 Composite same plasma near9 filler	USPĀT;	2004/03/10 18:53
		•	US-PGPUB;	,
			ЕРО; ЛРО;	
			DERWENT;	
			IBM TDB	
144	21	Interfac\$4 near9 (Composite matrix resin) and plasma near9 filler	USPAT;	2004/03/10 18:58
144	21	Interfacts 4 hears (Composite matrix resin) and prasma hears finer		2004/03/10 16.38
			US-PGPUB;	
			ЕРО; ЛРО;	
			DERWENT;	
			IBM_TDB	
145	355	427/488.ccls.	USPAT;	2004/03/10 18:58
			US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
			IBM TDB	
146	87	427/488.ccls. and (allylamine allyl glycidyl acrylamide ethyleneimine	USPĀT;	2004/03/10 19:02
		acrylonitrile pyridine diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB,	
		glycid\$5hexene allyl\$3mercaptan ((propylene alkylene) near3 (thiol	ЕРО; ЈРО;	
	İ	mercaptan)) propene\$1thiol)	DERWENT;	
		mercupumi) propericurumor)	IBM TDB	
148	2	107/188 cels and (silies (silien nears (diavide avide))) near? surface	USPAT;	2004/03/10 19:02
140	2	427/488.ccls. and (silica (silicon near5 (dioxide oxide))) near3 surface	US-PGPUB;	2007/03/10 17.02
		near9 (treat\$5 functionali\$9 modif\$8)		
			EPO; JPO;	
			DERWENT;	
1.45	_	(400/400 1 1/111 1 1111 1111 1111 1111 11	IBM_TDB	0004/02/10 10 02
147	2	(427/488.ccls. and (allylamine allyl glycidyl acrylamide ethyleneimine	USPAT;	2004/03/10 19:02
		acrylonitrile pyridine diamino\$1propane pyrrole epoxy\$3hexene	US-PGPUB;	
•		glycid\$5hexene allyl\$3mercaptan ((propylene alkylene) near3 (thiol	ЕРО; ЈРО;	
	!	mercaptan)) propene\$1thiol) ) and (silica (silicon near5 (dioxide	DERWENT;	
		oxide))) near3 surface near9 (treat\$5 functionali\$9 modif\$8)	IBM_TDB ¬	
149	76	427/488.ccls. and (silica (silicon near5 (dioxide oxide)))	USPAT;	2004/03/10 19:34
		· · · · · · · · · · · · · · · · · · ·	US-PGPUB;	
		•	ЕРО; ЈРО;	
			DERWENT;	
			IBM TDB	
150	31	(427/488.ccls. and (silica (silicon near5 (dioxide oxide)))) and	USPAT;	2004/03/10 19:33
150	31		US-PGPUB;	<u> 200-πουπουπουπουπουπουπουπουπουπουπουπουπουπ</u>
		(allylamine allyl glycidyl acrylamide ethyleneimine acrylonitrile	1	
•		pyridine diamino\$1propane pyrrole epoxy\$3hexene glycid\$5hexene	EPO; JPO;	
		allyl\$3mercaptan ((propylene alkylene) near3 (thiol mercaptan))	DERWENT;	
	[	propene\$1thiol)	IBM_TDB	

151	43	"4845132"	USPAT;	2004/03/10 19:14
			US-PGPUB;	
		·	ЕРО; ЛРО;	
			DERWENT;	
			IBM TDB	
152	0	("4423303" "4619861" "4685419" "4810524" "4867573") and	USPAT;	2004/03/10 19:31
		allyl\$2mercaptan	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
153	0	("4423303" "4619861" "4685419" "4810524" "4867573") and monomer	USPAT;	2004/03/10 19:34
		same (allyl\$2mercaptan allyl\$2thiol thiol)	US-PGPUB;	
		, , , , , , , , , , , , , , , , , , ,	ЕРО; ЈРО;	
			DERWENT;	*
	1		IBM TDB	
154	4	427/488.ccls. and monomer same (allyl\$2mercaptan allyl\$2thiol thiol)	USPAT;	2004/03/10 19:33
			US-PGPUB;	
			ЕРО; ЛРО;	
			DERWENT;	
			IBM TDB	
155	1	427/488.ccls. and (allyl\$2mercaptan allyl\$2thiol)	USPAT;	2004/03/10 19:33
	]		US-PGPUB;	
			ЕРО; ЛРО;	
			DERWENT;	
			IBM TDB	
156	12	("4423303" "4619861" "4685419" "4810524" "4867573").pn.	USPĀT;	2004/03/10 19:34
	i i		US-PGPUB;	
			ЕРО, ЈРО,	
			DERWENT;	
			IBM TDB	
157	1	(("4423303" "4619861" "4685419" "4810524" "4867573").pn. ) and	USPĀT;	2004/03/10 19:34
		(silica (silicon near5 (dioxide oxide)))	US-PGPUB;	
			ЕРО; ЈРО;	
			DERWENT;	
			IBM_TDB	
53	1	((yoon near3 tae-ho) (roh near3 joon)).in. and plasma	USPĀT;	2004/03/10 19:43
		•	US-PGPUB;	
			ЕРО, ЈРО,	
			DERWENT,	
			IBM TDB	